

**AMENDMENTS TO THE CLAIMS**

**This listing of claims will replace all prior versions and listings of claims in the application:**

**LISTING OF CLAIMS:**

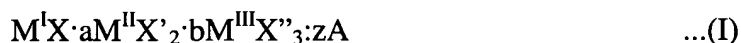
1-14. (canceled.)

15. (previously presented): A stimuable phosphor sheet comprising a support and a vapor deposited stimuable phosphor layer, and a protective silicate glass film, wherein the support has a frame unitedly protruded from a circumference of the support, the phosphor layer is enclosed with the frame, and the protective silicate glass film is airtightly sealed to the frame.

16. (original): The stimuable phosphor sheet of claim 15, wherein the support is made of quartz or metal.

17. (canceled).

18. (previously presented): The stimuable phosphor sheet of claim 15, wherein the stimuable phosphor is a stimuable alkali metal halide phosphor having an essential composition of the formula (1):



in which  $M^I$  represents at least one alkali metal selected from the group consisting of Li, Na, K, Rb and Cs;  $M^{II}$  represents at least one divalent metal selected from the group consisting of Be, Mg, Ca, Sr, Ba, Ni, Cu, Zn and Cd;  $M^{III}$  represents at least one trivalent metal selected from the group consisting of Sc, Y, La, Ce, Pr, Nd, Pm, Sm, Eu, Gd, Tb, Dy, Ho, Er, Tm, Yb, Lu, Al, Ga and In; each of X, X', and X'' independently represents at least one halogen atom selected from

the group consisting of F, Cl, Br and I; A represents at least one metal selected from the group consisting of Y, Ce, Pr, Nd, Sm, Eu, Gd, Tb, Dy, Ho, Er, Tm, Yb, Lu, Na, Mg, Cu, Ag, Tl and Bi; and each of a, b and z is a number respectively satisfying the conditions of  $0 \leq a < 0.5$ ,  $0 \leq b < 0.5$ ,  $0 \leq z < 0.2$ .

19. (original): A method for preparing a stimuable phosphor sheet of claim 15, comprising the steps of:

applying an electron beam to a stimuable phosphor or a source thereof in a vacuum to vaporize the phosphor or the source and depositing the vaporized phosphor or source on a support having a frame unitedly protruded from a circumference of the support in the area surrounded by the frame, and

providing a protective film on the phosphor layer and the frame of the support so as to airtightly seal a space surrounded by the frame.

20. (original): The method of claim 19, wherein the electron beam is applied to the stimuable phosphor or source thereof which is in the form of a solid having a relative density in the range of 80% to 98%, at an accelerating voltage in the range of 1.5 kV to 5.0 kV.